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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

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| In re application of: Wu et al. | § | Attorney Docket No. TSMC2002-1168 / |
| | § | 24061.27 |
| Serial No.: 10/687,314 | § | |
| | § | Customer No. 42717 |
| Filed: October 16, 2003 | § | |
| | § | Group Art Unit: 2826 |
| For: ELECTROSTATIC DISCHARGE | § | |
| PROTECTION STRUCTURE FOR DEEP | § | Examiner: Wilson, Scott R. |
| SUB-MICRON GATE OXIDE | § | |

Mail Stop Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

AMENDMENT

Dear Sir:

In response to the Office action of June 28, 2004, please amend the above-identified application as follows:

Amendments to the Specification begin on page 2 of this paper.

Amendments to the Claims are reflected in the listing of claims which begins on page 3 of this paper.

Remarks/Arguments begin on page 8 of this paper.

10/29/2004 SDIRETA1 00000022 10687314

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| 01 FC:1202 | 36.00 OP |
| 02 FC:1201 | 352.00 OP |